REMARKS

This amendment is filed in response to the Office Action dated November 15, 2007. In view of these amendments and remarks, this application should be allowed and the case passed to issue. No new matter is introduced by this amendment. The amendment to claim 1 is supported by originally filed claim 2. Claim 9 is amended to correct an informality.

Claims 1 and 3-14 are pending in this application. Claim 13 is withdrawn from consideration pursuant to an election of species requirement. Claims 1-12 and 14 are rejected. Claims 1 and 9 are amended in this response. Claim 2 has been canceled in this response.

Objections to the Specification

The specification was objected to as being unclear whether the positive electrode active material precursors are hydroxides or sulfates. This objection is traversed, and reconsideration and withdrawal thereof respectfully requested.

The specification clearly teaches on pages 23-25 that the sulfates are mixed with sodium hydroxide and hydroxides are precipitated from the solution.

As regards the differences between the comparative examples and Example 1, as clearly taught on pages 23-25 the positive electrode active material of the present invention is formed by a coprecipitation process. Whereas, as the comparative example positive electrode active material was formed by mixing powdered lithium hydroxide, powdered nickel hydroxide, and powdered manganese oxyhydroxide and subsequently baking the mixture, as taught on page 50 of the specification.

Claim Rejections Under 35 U.S.C. § 112

Claims 1-12 and 14 were rejected under 35 U.S.C. § 112, first paragraph, as failing to comply with written description requirement because "uniformly dispersed at the atomic level" is not supported by the disclosure as originally filed. This rejection is traversed, and reconsideration and withdrawal thercof respectfully requested.

The first full paragraph on page 24 clearly support "uniformly dispersed at the atomic level." Literal support of claim limitation is not required under U.S. patent law. It is clear from the first full paragraph on page 24 that Applicants had possession of the claimed invention and adequately describe the invention to one of ordinary skill in this art. As disclosed on page 24, "since manganese is prone to be oxidized . . . it's dispersion and formation of solid solution at the atomic level is insufficient." However, Applicants prevent insufficient dispersion and formation of solid solution at the atomic level and "produce a double hydroxide or triple hydroxide by allowing nickel, manganese, and cobalt elements to be present in one layered hydroxide without separation" by bubbling an inert gas such as nitrogen or argon in the aqueous solution or by adding a reducing agent.

Claims 1-12 and 14 were rejected under 35 U.S.C. § 112, first paragraph, because the specification allegedly does not enable the broad scope of the claims.

The Examiner has not met the burden of establishing a prima facie case of lack of enablement. The Examiner maintained that only one compound, LiCo_{1/3}Ni_{1/3}Mn_{1/3}O₂, is enabled by the disclosure. The examiner has provided no evidence or any basis as to why the claims are not enabled. It is not sufficient to merely argue that a claim is broad to allege lack of enablement. Further, the Examiner is mistaken that only one compound is exemplified. The specification teaches several examples of different positive electrode active materials in Table 5

on page 54. In addition, the specification (page 2) teaches a number of similar compounds that are outside the scope of the present claims in Table 1. Furthermore, the Examiner did not consider all the *In re Wands* factors, as is required, in reaching the determination of lack of enablement.

Contrary to the Examiner's assertions, claims are not unduly broad and there is great deal of direction provided by the inventors on how to make and use the claimed invention. The present specification includes a detailed explanation of how to form the claimed cathode active materials on pages 23-31 of the present specification. There are a number of working examples in the present specification. Furthermore, as explained in the MPEP § 2164.02, one or no working examples, alone, is not sufficient to sustain a lack of enablement rejection. For example, as the Court explained in *Home Diagnostics v. Lifescan, Inc.*, 381 F.3d 1352 (Fed. Cir. 2004), a single disclosed embodiment does not the scope of the claims to the single embodiment. Therefore, it is abundantly clear that the present specification, which teaches several embodiments, is surely enabling.

The Examiner averred that there is a level of unpredictability in the art. Applicants maintain that there is a level of unpredictability in all inventions. If there were no unpredictability then presumably every invention would be obvious. Applicants maintain that the Examiner-acknowledged level of unpredictability is an indicia of the unobviousness of the claimed invention. In light of the detailed specification supporting the claimed invention, the level of unpredictability and the quantity of experimentation to make and use the present invention is not undue.

Claims 4 and 7 were rejected under 35 U.S.C. § 112, second paragraph, because it is apparently not understood what "a $[\sqrt{3} \times \sqrt{3}]$ R30° when assigned as R3-m" means. This rejection is traversed, and reconsideration and withdrawal thereof respectfully requested.

The above terminology is commonly used in crystallography and would be understood by one of ordinary skill in this art. R3-m is a common technical term used to represent a crystallite structure. $[\sqrt{3} \times \sqrt{3}] R30^{\circ}$ is a technical term used to represent an array of atoms to which attention is paid. For example, LiCo_{1/2}Ni_{1/3}Mn_{1/3}O₂ contains the same number of Ni atoms, Mn atoms, and Co atoms. However, there are many variations in the arrangement of these three atoms. The $[\sqrt{3} \times \sqrt{3}] R30^{\circ}$ array is one such arrangement. Starting with the Ni atoms, in the case of a p(1X1) array, four Ni atoms are on the sites adjacent to each other, as shown in Kittel, Introduction to Solid State Physics, 7th Ed., attached to this response. The smallest rhombus shown in the left of Fig. 2(a) represents this array. Whereas, in the case of a p(2X2) array, four Ni atoms are on the sites corresponding to the vertices of the rhombus shown in the center of Fig. 2(a). Likewise in the case of the $[\sqrt{3} \times \sqrt{3}] R30^{\circ}$ array, four Ni atoms are on the sites corresponding to the vertices of the rhombus are on the sites

Claim Rejections Under 35 U.S.C. §§ 102 and 103

Claims 1-8, 10-12, and 14 were rejected under 35 U.S.C. § 102(b) as anticipated by or, in the alternative, under 35 U.S.C. § 103(a) as obvious over Ohzuku et al. (Chemistry Letters, CL-010390, Vol. 30 (2001), No. 7, pp. 642-43). The Examiner asserted that CL-010390 discloses a positive electrode material comprising LiCo_{1/3}Ni_{1/3}Mn_{1/3}O₂. This rejection is traversed, and

reconsideration and withdrawal thereof respectfully requested. The following is a comparison between the present invention, as claimed, and the cited prior art.

An aspect of the present invention, per claim 1, is a positive electrode active material comprising a lithium-containing composite oxide containing at least nickel and manganese elements, said positive electrode active material comprising primary particles of the composite oxide having a twining portion, the composite oxide further contains cobalt element, and the nickel, manganese, and cobalt elements are uniformly dispersed at the atomic level. The composite oxide has a layered crystal structure and the arrangement of oxygen atoms is a cubic close-packed structure.

The positive electrode active material of the present invention is not anticipated by or obvious in view of Ohzuku et al. because Ohzuku et al. do not disclose or suggest the composite oxide having a twining portion and the composite oxide further containing cobalt element, and the nickel, manganese, and cobalt elements are uniformly dispersed at the atomic level, and the composite oxide has a layered crystal structure and the arrangement of oxygen atoms is a cubic close-packed structure, as required by claim 1.

As explained in the declaration under 37 C.F.R. § 1.132 by Dr. Yoshizawa, which was filed February 20, 2007, positive electrode active material fabricated according to Chemistry Letters, CL-010390 exhibit a non-uniform elemental distribution. Exhibit A, as indicated by the widely-separated Co-rich and Co-poor areas, clearly shows a widely varying distribution of cobalt in the Chemistry Letters, CL-010390 positive electrode active material. In contrast thereto, Exhibits A and B clearly illustrate that cobalt is uniformly dispersed throughout the positive electrode material according to the present invention. As illustrated in Exhibits A and

B, the material according to the present invention is clearly distinguishable over the prior art material.

In the micrographs attached to the declaration, red indicates a high concentration of the element being measured, green represents a low concentration, and yellow represents an intermediate concentration, for each of Ni, Mn, Co. Thus, the Co map only shows Co concentration, the Ni map only shows Ni concentration, and the Mn map only shows Mn concentration.

Because CoCO₃ and nickel manganese hydroxide are used as a raw material in CL-010390, segregation of Co is observed in the LiCo_{1/3}Ni_{1/3}Mn_{1/3}O₂. In contrast thereto, in the present invention a triple hydroxide is used as the raw material (see page 24, lines 14-15) resulting in a favorable uniform dispersion of Co.

The Examiner asserted that Ohzuku et al. inherently disclose the claimed material. However, the fact that a certain result or characteristic may occur or be present in the prior art is not sufficient to establish the inherency of that result or characteristic. *In re Rijckaert*, 9 F.3d 1531, 1534, 28 USPQ2d 1955, 1957 (Fed. Cir. 1993). "Inherency ... may not be established by probabilities or possibilities. The mere fact that a certain thing may result from a given set of circumstances is not sufficient." *In re Robertson*, 169 F.3d 743, 745, 49 USPQ2d 1949, 1950-51 (Fed. Cir. 1999)(citations omitted). In view of the data presented in Dr. Yoshizawa's declaration it is clear that CL-010390 does not inherently disclose the positive electrode active material, as required by claim 1.

The factual determination of lack of novelty under 35 U.S.C. § 102 requires the disclosure in a single reference of each element of a claimed invention. *Helifix Ltd. v. Blok-Lok Ltd.*, 208 F.3d 1339, 54 USPQ2d 1299 (Fed. Cir. 2000); *Electro Medical Systems S.A. v. Cooper*

Life Sciences, Inc., 34 F.3d 1048, 32 USPQ2d 1017 (Fed. Cir. 1994); Hoover Group, Inc. v. Custom Metalcraft, Inc., 66 F.3d 399, 36 USPQ2d 1101 (Fed. Cir. 1995); Minnesota Mining & Manufacturing Co. v. Johnson & Johnson Orthopaedics, Inc., 976 F.2d 1559, 24 USPQ2d 1321 (Fed. Cir. 1992); Verdegaal Bros. v. Unlon Oil Co. of California, 814 F.2d 628, 631, 2 USPQ2d 1051 (Fed. Cir. 1987). Because Ohzuku et al. do not disclose positive electrode active material comprising primary particles of the composite oxide having a twining portion, containing cobalt element, and the nickel, manganese, and cobalt elements are uniformly dispersed at the atomic level, and the composite oxide has a layered crystal structure and the arrangement of oxygen atoms is a cubic close-packed structure, as required by claim 1, Ohzuku et al. do not anticipate claim 1.

Obviousness can be established by combining or modifying the teachings of the prior art to produce the claimed invention where there is some teaching, suggestion, or motivation to do so found either in the references themselves or in the knowledge generally available to one of ordinary skill in the art. *In re Kotzab*, 217 F.3d 1365, 1370 55 USPQ2d 1313, 1317 (Fed. Cir. 2000); *In re Jones*, 958 F.2d 347, 21 L SPQ2d 1941 (Fcd. Cir. 1992); *In re Fine*, F.2d 1071, 5 USPQ2d 1596 (Fed. Cir. 1988). Obzuku et al. do not suggest positive electrode active material comprising primary particles of the composite oxide having a twining portion, containing cobalt element, and the nickel, manganese, and cobalt elements are uniformly dispersed at the atomic level, and the composite oxide has a layered crystal structure and the arrangement of oxygen atoms is a cubic close-packed structure, as required by claim 1.

The only teaching of the claimed positive electrode active material comprising primary particles of the composite oxide having a twining portion, containing cobalt element, and the nickel, manganese, and cobalt elements are uniformly dispersed at the atomic level, and the

composite oxide has a layered crystal structure and the arrangement of oxygen atoms is a cubic close-packed structure, is found in Applicants' disclosure. However, the teaching or suggestion to make a claimed combination and the reasonable expectation of success must not be based on applicant's disclosure. *In re Vaeck*, 947 F.2d 488, 20 USPQ2d 1438 (Fed. Cir. 1991).

Claims 1-8, 10-12, and 14 were rejected under 35 U.S.C. § 102(b) as anticipated by or, in the alternative as obvious over Thackeray et al. (US 2006/0099508). The Examiner asserted that Thackeray et al. disclose LiCo_{1/3}Ni_{1/3}Min_{1/3}O₂ and the claimed features would have been inherent.

Claim 9 was rejected under 35 U.S.C. § 103(a) as being unpatentable over Thackeray et al. in view of Miyasaka (US 6,416,902). The Examiner alleged that Thackeray et al. do not disclose the claimed primary and secondary particles. The Examiner averred that Miyasaka discloses the primary and secondary particles and that it would have been obvious to make two different particle size distributions to enhance packing because the smaller particles would occupy the voids between the larger particles. The Examiner further pointed out that Miyasaka teaches that secondary particles consist of aggregated primary particles.

These rejections are traversed, and reconsideration and withdrawal thercof respectfully requested.

Initially, it is noted that the Examiner has not established that Thackeray et al. is prior art. Thackeray et al. has a US filing date of November 10, 2005, which is well after the July 30, 2003 filing date of the present application. The Examiner has the burden of proving that the earlier filed priority applications of Thackeray et al. disclose the claimed invention, and the Examiner has not done so. Whether or not Thackeray et al. is prior art, however, the Yoshizawa declaration proves that the claimed "uniformly dispersed" is not inherent and there is no teaching or suggestion in Thackeray et al. of the claimed positive electrode active material comprising

primary particles of the composite oxide having a twining portion, containing cobalt element, and the nickel, manganese, and cobalt elements are uniformly dispersed at the atomic level, and the composite oxide has a layered crystal structure and the arrangement of oxygen atoms is a cubic close-packed structure, as required by claim 1.

Miyasaka does not cure the deficiencies of Thackeray et al., as Miyasaka does not suggest positive electrode active material comprising primary particles of the composite oxide having a twining portion, containing cobalt element, and the nickel, manganese, and cobalt elements are uniformly dispersed at the atomic level, and the composite oxide has a layered crystal structure and the arrangement of oxygen atoms is a cubic close-packed structure, as required by claim 1.

Claim 9 was rejected under 35 U.S.C. § 103(a) as obvious over Ohzuku et al. (Chemistry Letters, CL-010390, Vol. 30 (2001), No. 7, pp. 642-43) in view of Miyasaka (U.S. Pat. No. 6,416,902). This rejection is traversed and reconsideration and withdrawal thereof respectfully requested.

Claim 9 depends from claim 1 and is allowable for at least the same reasons as claim 1. The combination of Ohzuku et al. and Miyasaka does not suggest the claimed positive electrode active material because Miyasaka does not cure the deficiencies of Ohzuku et al. Miyasaka does not suggest positive electrode active material comprising primary particles of the composite oxide having a twining portion, containing cobalt element, and the nickel, manganese, and cobalt elements are uniformly dispersed at the atomic level, and the composite oxide has a layered crystal structure and the arrangement of oxygen atoms is a cubic close-packed structure, as required by claim 1.

The dependent claims are allowable for at least the same reasons as independent claim 1, and further distinguish the claimed positive electrode active material.

In view of the above amendments and remarks, Applicants submit that this application should be allowed and passed to issue. If there are any questions regarding this Amendment or the application in general, a telephone call to the undersigned would be appreciated to expedite the prosecution of the application.

To the extent necessary, a petition for an extension of time under 37 C.F.R. § 1.136 is hereby made. Please charge any shortage in fees due in connection with the filing of this paper, including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,

McDERMOTT WILL & EMERY LLP

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as our correspondence address.

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Date: March 17, 2008

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CHARLES KITTEL

Introduction to

大坂市立大学学街情報総合センター

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About the Author

Charles Kittel taught solid state physics at Berkeley from 1951 to 1978; earlier he was a member of the solid state group at the Bell Laboratories. His undergrachate work was at M.J.T. and at Cambridge University, followed by graduate work at the University of Wisconsin. He is a member of the National Academy of Science and of the American Academy of Arts and Sciences.

His research in solids began with studies of ferromagnetic, antiferromagnetic, and paramagnetic resonance, along with work on magnetic domains, spin neare, and domain boundaries in ferromagnets and ferroelectries. His work on the single domain structure of fine particles has had broad application in magnetic domain structure of fine particles has had broad application in magnetical particles has had broad application in magnetic domain structure of sile with collaborators at Barkeley be did the first work on cyclotron resonance in semiconductors, which led to the understanding of the band structure of silicon, germanium, and indium antimonide, together with the theory of their impurity states. He also worked on the interpretation of magnetoplasma resonance in semiconductors and of Alfvén resonance in electron-hole drops in germanium.

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Preta

This book is the seventh edition of an elementary text on solid state phi for senior and beginning graduate students of physical science and engineed. The book is an update of the sixth edition of 1986 and includes additi improvements, and corrections made in that edition in 13 successive printin which it was time to find howe been added or discussed more fully, thus temperature in the field have been added or discussed more fully, thus microscopy are displayed, the treatment of fiber optics is expanded. Then discussions, among other topics, of nanostructures, superlattices, Bl Wannier levels, Zener tunneling, light-emitting diodes, and new mag materials. The additions have been made within a boundary condition inter to keep the text within one volume and at a reasonable price.

The theoretical level of the text itself has not been changed. There is a discussion of useful materials. The treatment of elastic constants and elwayers which was dropped after the fourth edition has now been returned cause, as many have pointed out, the matter is useful and not easily soccestleswhere. The treatment of superconductors is much more estensive the usual in a text at this level: either you do it or you don't.

Solid state physics is concerned with the properties, often astonishing Solid state physics is concerned with the properties, othen astonishing often of great utility, that result from the distribution of electrous in me semiconductors, and insulators. The book also tells how the excitations imperfections of real solids can be understood with simple models whose p and scope are now firmly established. The subject matter supports a profit interplay of experiment, application, and theory. The book, in English an many translations, has helped give soveral generations of students a pictuthe process. Students also find the field attractive because of the frequent bility of working in small groups.

Instructors will use the book as the foundation of a course to their lostructors will use the book as the introduction, selection and c of the basic material. If shudents have a significant preparation in clemes of the basic material, if shudents have a significant preparation in clemes quantum mechanics, they will like to begin with the quantum theory of

BEFERENCES

3. Feenier. (a) Treat an F center as a free electron of mass an moving in the field of a point charge e in a medium of dielectric constant e = n. what is the 1.1.2p enongy difference of P centers in NaCI? (b) Compare from Table 3 the P center archadon energy to NaCl with the 3x-3p energy difference of the free sodium atom.

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Surface and Interface Physics

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Heconstruction and relations	SHRBACR CRYSTALLOCRAPHY	Beflection high-energy electron diffraction	STINEACE PLECTRONIC STRUCTURE		The metal	Surface aloths	Tangent's rarino transport	WALNUT THE THE DAMENSTONAL CHANNEL	Throng Countried Holl affort (IDEE)	TOTO & was leastlems	Proctional quantitaed Hall effect (FQHB)	SNOFE NIII	and the state of t	Cain colle and photomologic detectors	Scholiky barrier		HETEROSTRUCTURES	n-N heterejunction	SEMICONDUCTOR LASERS	LICHT.BMITTING DIODES	SCANNING TUNNELING MICROSCOPY	PROBLEMS	WOTH THE COURSE OF STREET OF STREET	1. Delitacion from a meta miss and all the factors from the factors and the fa	2, Surface substitutes at electric quantum actor.	3. Southflyorde many cales: or a series

CHAPTER 19: SURPACE AND INTERFACE PHYSICS

Reconstruction and Relaxation

The surface of a crystalline solid in vacuum is generally defined as the approximately three, outermost atomic layers of the solid that differ si cauth from the bulk. The surface may be entirely clean or it may have to atoms deposited on it or incorporated in I. The bulk of the crystal is calle substrate.

If the surface is clean the top layer may be either reconstructed or, s times, unreconstructed. In unreconstructed surfaces the atomic arrangem in registry with that of the bulk except for an interlayer spacing change (e multidayer relaxation) at the top rurface.

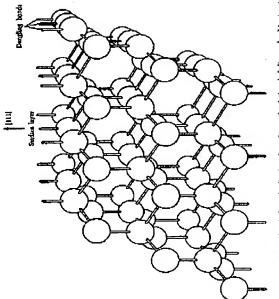
The shrinking of the intentayer distance between the first and second of atoms with respect to subsequent layers in the bulk is a rather domiphenomenon. The surface may be thought of as an intermediate between distance materials are thought of as an intermediate between distance materials are much smaller than in the bulk, there is a rational the surface relaxation. This may be contrasted with reconstruction where relaxation of atoms yields new surface primitive cells. In relaxation the situation of atoms yields new surface primitive cells. In relaxation the situation of atoms yields new surface plane as it was according to the print don of the bulk cell on the surface; only their distance from the bulk chan

von use duty car on the surface; only their distance from the bulk chan Experimental values of the top-layer relaxation for metals are give Table J. Note the frequency of occurrence of contractions in the interl spacing at the surface.

Sometimes in metals, but most often in nonmetals, the stoms in the lace layer form superstructures in which the stoms in the layer are no registry with the atoms in corresponding layers in the substrate. Surface required on the surface in corresponding layers in the substrate. Surface required to a consequence of a rearrangement of broken covalent or it bonds at the surface. Under such conditions the atoms at the surface bunch i rows with alternately larger and smaller spacings than in the built. That is, some crystals held together dy valence bonds, creation of a surface would le unsaturated bonds daugling into space (Fig. 1). The energy may then be it ered if neighboring atoms approach each other and form bonds with the otherwise imused valence electrons. Atomic displacements can be as large 0.5 Å.

Reconstruction does not necessarily require formation of a superstructu For example, on GaAs (110) surfaces a Ga-As bond rotation occurs that leas the point group infact. The driving force is electron transfer from Ga to , which fills the daughing bands on As and depietes them on Ga.

Surfaces of planes norminally of high inchies may be built up of low ind



Phone 1 Draging braits from the (111) surfuse of a covalently bonded dismond colike structuse. (After N. Prutton, Surface pripries, Clarendon, 1975.)

Table 1 Relaration of topmost interlayer spacing at unreconstructed clean metal

ervo i ur.

Aber F. Jona and P. M. Marous, in "The Structure of Surinoss II," eds. J. F. van der Veen and M. A. Van Howe, Springer-Verlag (Heidelberg, 1988), p. 80)

Chemical symbol (interlayer spacing change from bulk value).

	hen(0001)	He (-541). Sc (-242). Tr (-345). Zr (-145)
,		
	(111)	AL (*1.8), Ag (5.8), Co (-0.18), M (+1.8), MG (5.8)
,	box(110)	Fe (+0.5%), Na (0%), V (-0.3%), W (0%)
,	(cc(100)	Al (078), Cu (-158), Rh (0%)
	ber(100)	Po (-5%), Mo (-9,5%), Ta (-11%), V (-7%), W (-8%)
, .,	fec(110)	Al (-8.5%), Ag (-8%), Cu (-8.5%), Nf (-8.5%), Pb (-18%),
e		Rb (-3%)
,	hep(10-10)	Re (-17%)
.,	boc(211)	Fe (-10%), W (-12%)
.,	(cc(311)	Al (-13%), Ni (-16%), Cu (-5%)
.,	bcc(310)	Fe (-16%)
	היומוא	「なみすし」ない。
	(cc(310)	AJ (~15.5%)
	bcc(111)	Fe (-17%)
	box(210)	Fe (-22%)

planes separated by steps one (or two) atoms in height. Such terrace-step arerangements are important in evaporation and description because the attachment energy of atoms is often low at the steps and at kinks in the steps. The chemical activity of such sites may be high. The pressures of periodic arrays of stops may be detected by double and triple beams of diffraction in LEED (see below) experiments.

SURFACE CRYSTALLOGRAPHY

The surface structure is in general diperiodic. This does not necessarily mean that all its atoms lie to a plane, but rather that the structure is periodic only in two dimensions. The surface structure can be the structure of fareign material deposited on the substrate or it can be the scheage of this pure substrate.

In Chapter I we used the term Bravais lattice for the array of equivalent points in two or in three dimensions, that is, for diperiodic or triperiodic structures. In the physics of surfaces it is common to speak of a two-dimensional lattice. Further, the area unit may be called a mesh.

We showed in Fig. 1 9 fair of the five nets massible for a diperiodic struc-

ture, the fifth net is the general oblique net, with no special symmetry κ between the mesh basis vectors $\mathbf{a_b}$ a. Thus the five distinct nets a oblique, square, hexagonal, rectangular, and centered rectangular.

19 Surface and Inter

The substrate net parallel to the surface is used as the reference net if description of the surface. For example, if the surface of a cubic sub crystal is the (111) surface, the substrate net is heagenal (Fig. 1.9b), as surface net is referred to these axes.

The vectors c, c, that define the mesh of the surface structure m. expressed in terms of the reference net s., s, by a matrix operation P.

$$\begin{pmatrix} c_1 \\ c_2 \end{pmatrix} = P \begin{pmatrix} a_1 \\ a_2 \end{pmatrix} = \begin{pmatrix} P_{11} & P_{12} \\ P_{21} & P_{22} \end{pmatrix} \begin{pmatrix} a_1 \\ a_2 \end{pmatrix}$$

Provided that the included angles of the two meshes are equal, the s hand notation due to E. A. Wood may be used. In this notation, which is w used, the relation of the mesh e_k , e_k to the reference mesh a_k , a_k is express

$$\left(\frac{\Omega_{\perp}}{a_{\perp}} \times \frac{c_{\alpha}}{a_{\alpha}}\right)$$
R α_{α}

in terms of the lengths of the mesh basis vectors and the angle α of relation R of the two meshes. If $\alpha=0$, the angle is oratived. Examples o Wood notation are given in Fig. 2.

The reciprocal net vectors of the surface mesh may be written as coefined by

$$c_1 \cdot c_2^4 = c_2 \cdot c_3^4 = 0$$
 $c_1 \cdot c_1^4 = c_2 \cdot c_3^4 = 8\pi \text{ (or 1)}$

Here the 2r (or 1) indicates that two conventions are in use. The definition used in Fig. 3 may be compared with the definitions (2.10) and (2.11) for reciprocal lattice vectors of a triperiodic lattice.

The reolgrocal not points of a diperiodic net may be thought of—when are in three dimensions—as rode. The rods are infinite in extent and norm the surface plane, where they pass through the redprocal not points. It on helpful to think of the rods as generated by a triperiodic lattice which is panded without limit along one of its ares. Then the reciprocal lattice positions this axis are moved closer begether and in the limit form a rod.

The usefulness of the rod concept comes out with the Ewald aphere struction explained in Fig. 2.8. Diffruction occurs everywhere the Everythere intercepts a reciprocal net rod. Each diffracted beam is labelled with indices kk of the reciprocal net vector.

formulag the beam.

Low anargy electron diffraction (I.KRD) is illustrated by Fig. 4. The el

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lines me the rade of the reciprocal rate.

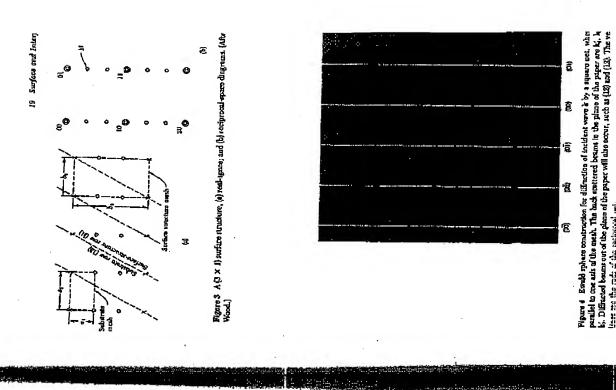


Figure 2. Surface over of adjusted alarm. The circles represent stooms in the top layer of the substrate. In (2) the designation factlil] means the (111) face of an five structure. This face determines a reference net. The bines represent ordered overlayers, with adjusts at the intersections of nation p(1 × 1) in (a) is a primitive mesh unit for which the basis is identical with the basis of the two lines. The intersection points represent diperiodic nets (latices in two dimensions). The desig-¥ X X E x E

reference net. In (b) the o(2 × 2) mash untl is a centered meth with batts vectors before as long as those of the reference net. Atomic adorption on metals takes place most offen into those authore sizes (ballow sizes) that maximize the normber of nearest-neighbor stocks on the substrata, (After Van Hove.)



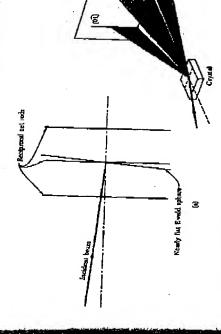


Figure 6 The RHEKD methed. In (9) the high energy incident electron beam at a glancing an to the prints in the separation between the complete prints of suggestables, as large that the surface areaty Bat to relation to the separation between adjacent root of the respirosal nat. The farmation diffraction lates on a plane serves is shown in (b) (After Prutton.) electron may be neglected—move than 100 Å from the surface. The Ferr level is the electrochemical potential of the electrons in the metal.

Typical values of electron work functions are given in Table 2. The orient tion of the exposed crystal face affects the value of the work function becaus the strength of the electric double layer at the surface depends on the concer tration of surface positive ion cores. The double layer exists because the surfac ions are in an asymmetrical environment, with vacuum (or an adsorbed foreig atom layer) on one ride and the substrate on the other side,

The work function is equal to the threshold energy for photoelectric emit cion at absolute zero. If he is the energy of an incident photon, then the Efr stein equation is here W+T, where Γ is the kinetic energy of the emitte electron and W is the work function.

Thermionic Emission

The rate of emission of thermionic electrons depends exponentially on the work function. The derivation follows.

electrons in a metal at temperature $\eta(=k_BT)$ and chemical potential μ . We trea the electrons in the vacuum as an ideal gas, so that their chembal potential it We first find the electron concentration in vacuum in equilibrium with

 $\mu = \mu_{\rm ext} + \tau \log(n l n_{\rm O})$ by IF, Chapter 8, Here

88.8 eV. The diffraction angle is greater at the lower energy. (After G. A. Somodal, Chamistry in two dimensions: angloces.) Figure § LEED getterns from a Pt(111) crystal surface for incident electron energies of 51 and

tron energy is typically in the range 10-1000 eV. This is the arrangement with which Davisson and Cermer in 1927 discovered the wave nature of the electron. An experimental pattern is shown in Fig. 5.

Reflection High-Energy Electron Diffraction. In the RHESD method a beam of high-energy electrons is directed upon a crystal surface at grazing component of the incoming wavevector to be very small, which will minimize incidence. By adjustment of the angle of incidence one can arrange the normal the penetration of the electron beam and enhance the rols of the crystal sur-

It follows that the Ewald sphere will be nearly a flat surface in the central scattering region. The intercept of the rods of the reciprocal net with the nearly The radius k of the Ewald sphere for 100 keV electrons will be $\approx 10^3~{\rm A}^{-4}$ which is much longer than the shortest reciprocal lattice vector 2m/a $\sim 1~{
m \AA}^{-1}$ lat sphere will be nearly a line when the beam is directed at grazing incidence. The experimental arrangement is shown in Fig. 6.

IURFACE ELECTRONIC STRUCTURE

Work Function

The work function W of the unform surface of a metal is defined as the difference in potential energy of an electron between the vacuum level and the Fermi lovel. The vacuum level is the energy of an electron at rest at a point sufficiently far outside the surface so that the electrostatic image force on the

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